Attorney's Docket No. 033339/300610

IN THE UNITED STATES DESIGNATED OF THE PROPERTY 12 OCT 2005

In re: Auvray et al.

Attn: DO/US

International Appl. No.: PCT/EP03/08827 International Filing Date: April 22, 2003

For: A PROCESS FOR MODIFYING AT LEAST ONE ELECTRICAL PROPERTY OF A NANOTUBE OR A NANOWIRE AND A TRANSISTOR INCORPORATING IT

Mail Stop PCT Commissioner for Patents Alexandria, VA 22313-1450

INFORMATION DISCLOSURE STATEMENT

Sir:

The patents listed on the attached PTO-1449 were cited in the International Search Report of corresponding International Application No. PCT/EP03/08827. A copy of the Search Report and documents cited therein are enclosed for the Examiner's convenience.

The Examiner may wish to consider the notations on the Search Report itself regarding the relevance of each item. It is requested that the Examiner consider these references and officially make them of record in accordance with the provisions of 37 C.F.R. § 1.97 and Section 609 of the MPEP. By submitting the listed documents, Applicant in no way makes any admission as to the prior art status of the listed documents, but is instead submitting the listed documents for the sake of full disclosure.

Respectfully submitted,

Raymond O. Linker, Jr. Registration No. 26,419

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Janet F. Sherrill

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STATEMENT BY APPLICANT (Use as many sheets as necessary)						Examiner Name							
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^{*}Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.